Progress on the ORNL high power, high particle flux helicon hydrogen plasma source\textsuperscript{1} RICHARD GOULDING, G. CHEN, S.J. MEITNER, L.W. OWEN, F.W. BAITY, T.M. BIEWER, J.B.O. CAUGHMAN, M.J. COLE, D.A. RASMUSSEN, D.O. SPARKS, Oak Ridge National Laboratory — A high power, high particle flux helicon plasma source has been constructed at ORNL. This electrode-less, high ionization fraction RF plasma source is a short pulse (≤ 3 s) prototype that will provide data needed to design a long pulse version for incorporation into a high power flux (∼ 20 MW/m\textsuperscript{2}) linear plasma-surface interaction (PSI) test stand. The source will produce high density hydrogen and deuterium plasmas with density >10\textsuperscript{19} m\textsuperscript{-3}, and total ion production ≥ 10\textsuperscript{21}s\textsuperscript{-1}. It consists of a 1.3 m long, 15 cm diameter vacuum chamber, with a helical antenna transmitting rf power at f= 10-26 MHz through a cylindrical aluminum nitride (AlN) vacuum window 30 cm in length, and four circular coils creating an axial magnetic field with |B| ≤ 0.8T. Results of initial operation will be presented.

\textsuperscript{1}Oak Ridge National Laboratory, managed by UT-Battelle, LLC, for the U.S. Dept. of Energy under contract DE-AC05-00OR22725.

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Date submitted: 26 Jul 2010  
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